



**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**  
**In re Application of: BECKER, R.C. et al.**

**Serial No.: 09/560,518**

**Filed: 04/28/2000**

**For: METHOD FOR DEPOSITING BORON-RICH COATINGS**

**Examiner: PADGETT, MARIANNE**

**Art Unit: 1762**

**Att'y. Docket No.: Refrac-3**

I hereby certify that this document and all documents enclosed herewith are being sent to the Commissioner of Patents, Washington, DC 20231, postage prepaid via Express Mail, Express Mail Cert # EV 416 585 6305 on 26 July 2002, name: D.N. Halgren, signed: D.N. Halgren

HON. COMMISSIONER FOR PATENTS  
WASHINGTON, DC 20231

AMENDMENT

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AUG 01 2002

**TC 1700**

Dear Sir or Madam:

In response to the Examiner's letter dated 02/26/2002 in regard to the above-identified pending U.S. Patent Application, please amend that Application as follows:

In the Specification:

al On page 5, on line 2 thereof, Add -- "Boron-rich" defined as an atomic ratio of boron to all other elements, equal to 20 or greater. This covers a coating composed substantially of boron at slightly greater than 95 atomic percent, to define a purity range between metallurgical grade and high grade boron."—